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Attorney Docket No.: 01CON211P

### IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of: Kar Roy, et al.

Serial No.: 10/073,751

Filed: February 9, 2002

For: Method for Fabricating a Metal

Resistor in an IC Chip and Related

Structure

Art Unit: 2815 CENTRAL FAX CENTER

Examiner: Chu, Chris C. SEP 2 0 2004

#### RESPONSE TO FINAL OFFICE ACTION

Mail Stop AF Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Dear Sir/Madam:

This is in response to the *Final Office Action* dated July 14, 2004 in the above-referenced patent application. Please enter and consider the following remarks.

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